

**REPLACEMENT CLAIMS**

*C<sub>1</sub>* *Sub D1* 1. (Thrice Amended) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol and at least two inorganic acids, wherein one of said inorganic acids is selected from the group consisting of hydrofluoric acid, phosphoric acid, sulfuric acid, boric acid, carbonic acid, perchloric acid and sulfurous acid.

*C<sub>2</sub>* *Sub E3* 22. (Amended) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol and at least two different inorganic acids selected from the group consisting of hydrofluoric acid, phosphoric acid, sulfuric acid, boric acid, carbonic acid, perchloric acid and sulfurous acid.

82. (Twice Amended) An etching composition consisting essentially of:

*C<sub>3</sub>* a non-aqueous composition of isopropanol and at least two inorganic acids, wherein one of said inorganic acids is selected from the group consisting of hydrofluoric acid, phosphoric acid, sulfuric acid, boric acid, carbonic acid, perchloric acid and sulfurous acid.

83. (Twice Amended) An etching composition consisting essentially of:

a non-aqueous composition of propylene glycol and at least two inorganic acids, wherein one of said inorganic acids is selected from the group consisting of hydrofluoric acid, phosphoric acid, sulfuric acid, boric acid, carbonic acid, perchloric acid and sulfurous acid.

87. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, hydrofluoric acid, and at least another inorganic acid.

88. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, phosphoric acid, and at least another inorganic acid.

89. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, sulfuric acid, and at least another inorganic acid.

90. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, boric acid, and at least another inorganic acid.

91. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, perchloric acid, and at least another inorganic acid.

92. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, carbonic acid, and at least another inorganic acid.

*C. J. Reed*  
93. (New) An etching composition consisting essentially of:

a non-aqueous composition of an alcohol, sulfurous acid, and at least one inorganic acid.

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